

Electronic Patent Application Fee Transmittal

Application Number:	10781920
Filing Date:	20-Feb-2004
Title of Invention:	Method for fabricating a resist mask for patterning semiconductor substrates
First Named Inventor/Applicant Name:	Odo Wunnicke
Filer:	Ira Stuart Matsil/Natalie Swider
Attorney Docket Number:	INF 2004 SP 00138 US

Filed as Large Entity

Utility Filing Fees

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
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Basic Filing:

Pages:

Claims:

Miscellaneous-Filing:

Petition:

Patent-Appeals-and-Interference:

Notice of appeal	1401	1	510	510
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Post-Allowance-and-Post-Issuance:

Extension-of-Time:

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Extension - 1 month with \$0 paid	1251	1	120	120
Miscellaneous:				
Total in USD (\$)				630